Applicant(s): I	TAL LETTER (Large Entity)		Docket No. 11675.114		
Serial No 08/846,67		ling Date ril 30, 1997	Examiner Goudreau	1	Group Art Unit 1765	
De James State Company	DOPED SILICON DIC	OXIDE AS ETCH STOF	P FOR SELECTIVE ET	TCH OF DO	OPED SILICON DIOXID	
Transmitted here		E ASSISTANT COMMI		NTS:		
		in the above-identified				
		CLAIMS AS A	MENDED			
	CLAIMS REMAINING	HIGHEST#	NUMBER EXTRA		ADDITIONAL	
	AFTER AMENDMENT	PREV. PAID FOR	CLAIMS PRESENT	RATE	FEE	
TOTAL CLAIMS	51 -	54 =		x \$18.0		
NDEP. CLAIMS	7 -	8 =	0	x \$78.0	- 	
Multiple Depender	nt Claims (check if app	plicable)			\$0.00	
- <u> </u>		TOTAL ADDITIONAL	FEE FOR THIS AME	NDMENT	\$0.00	
Please ch	onal fee is required for arge Deposit Account	No.	in the amount of		V 5.50	
Please ch. A duplicate A check in The Communic A duplicate A duplicate A ny a Any p	arge Deposit Account e copy of this sheet is a the amount of missioner is hereby au action or credit any ove e copy of this sheet is additional filing fees recontent application processing Signature dro, Reg. No. 34,521 DEGGER & SEELEY ower	No. enclosed. to cover the filing thorized to charge payr erpayment to Deposit A enclosed. quired under 37 C.F.R. essing fees under 37 C	1.16. CFR 1.17. ated: November 2/4,1	999		



PATENT APPLICATION Docket No: 11675.114 4a 12/8/99

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re application of:) 00	030	77 71
	Kei-Yu Ko) Group Aft	() ()	AIBU.
Serial No.:	08/846,671) Unit 17 🗟	1999	
Filed:	April 30, 1997	ROOM		
For:	UNDOPED SILICON DIOXIDE AS ETCH STOP FOR SELECTIVE ETCH OF DOPED SILICON DIOXIDE	,)))		
Examiner:	George A. Goudreau))		

AMENDMENT "A" AND ELECTION IN RESPONSE TO RESTRICTION REQUIREMENT

Honorable Commissioner of Patents and Trademarks Washington, D.C. 20231

Sir:

IN THE CLAIMS:

Please cancel Claims 47-49 without prejudice to the filing of a divisional patent application.